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Supporting Information

Self-Assembly Supramolecular Structure through Complementary Multiple Hydrogen Bonding of Heteronucleobase-Multifunctionalized Polyhedral Oligomeric Silsesquioxanes (POSS) Complexes

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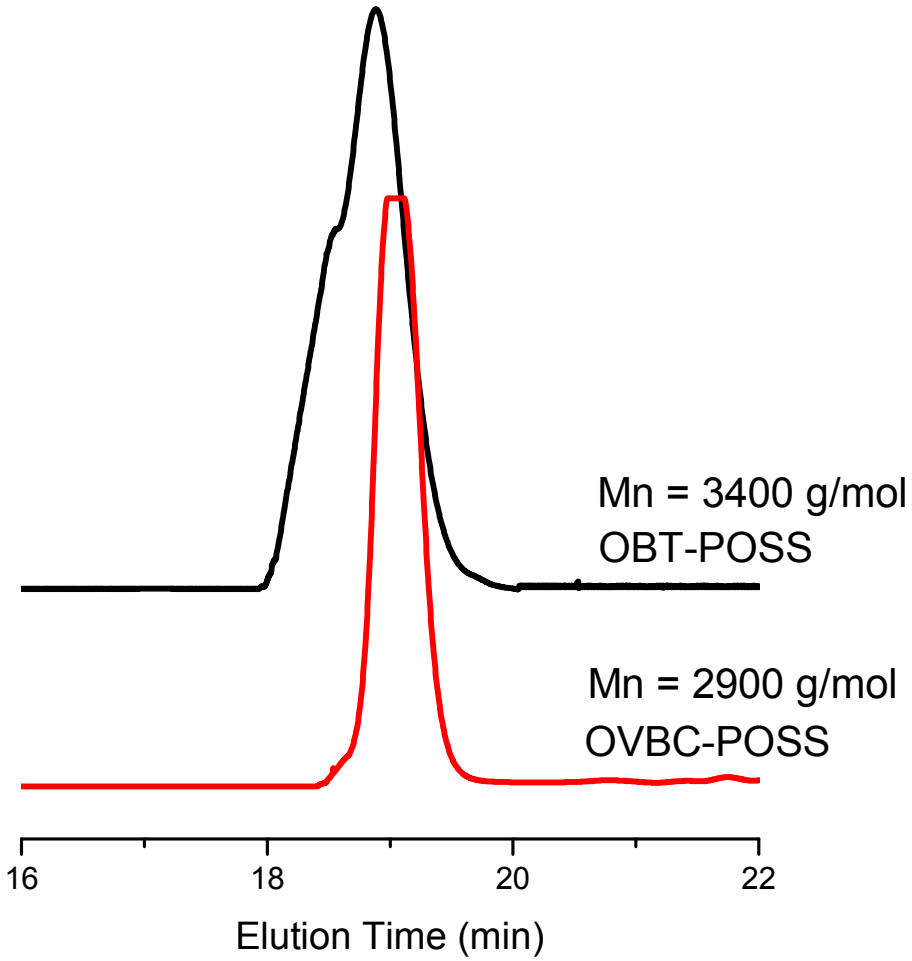

Figure S1: GPC analyses of OBT-POSS and OVBC-POSS

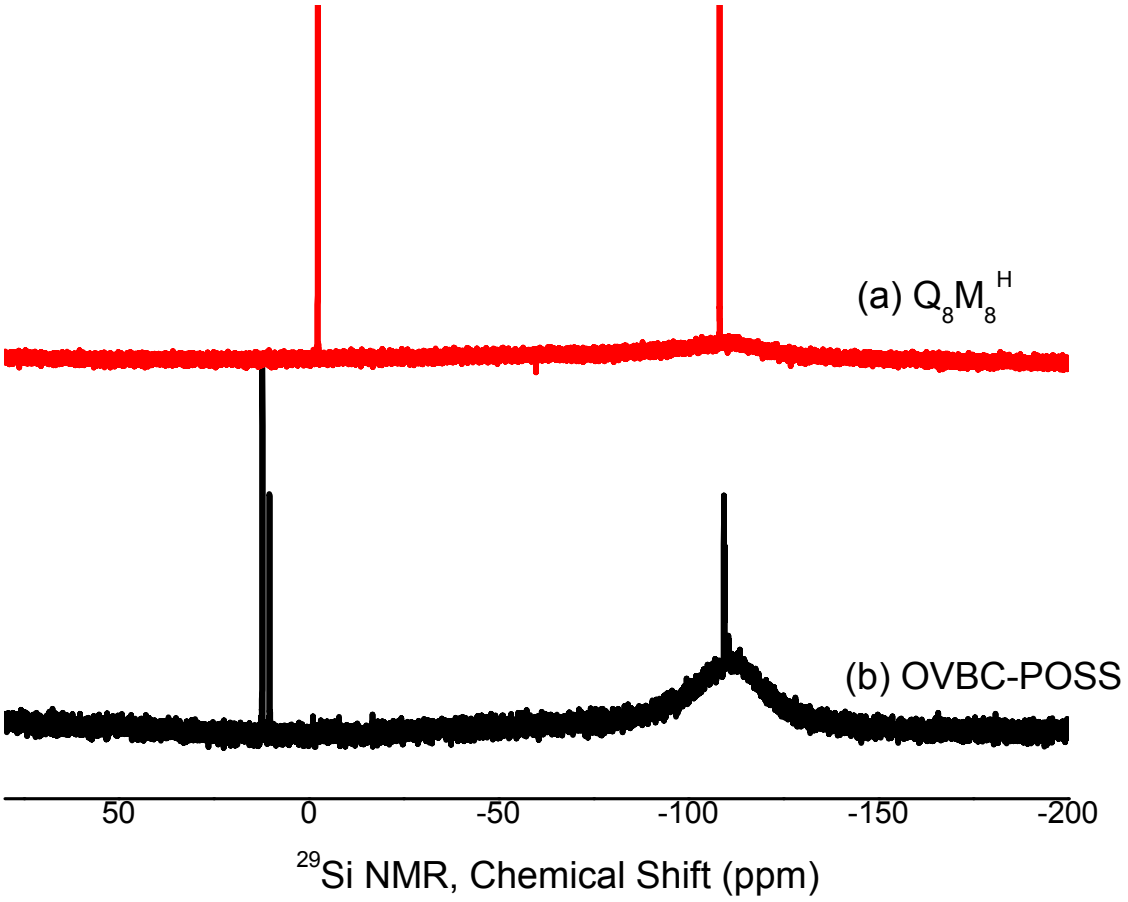

Figure S2: ^{29}Si NMR of (a) $Q_8M_8^H$, and (b) OVBC-POSS.

The ^{29}Si NMR spectrum of $Q_8M_8^H$ in Figure S1 shows two peaks at $(CH_3)_2$Si-H: -2.1 ppm and Si-O-Si $(CH_3)_2$H: -109.3 ppm. In addition, the ^{29}Si NMR spectrum of OVBC-POSS shows three peaks at 10.28 ppm for $(CH_3)_2$Si-$(CHCH_3)$ and 12.16 ppm for $(CH_3)_2$Si-CH_2-CH_2- and -109.2 ppm for Si-O-Si$(CH_3)_2$H. The chemical shift clearly indicates that the hydrosilylation reaction occurred to completion under the reaction conditions.

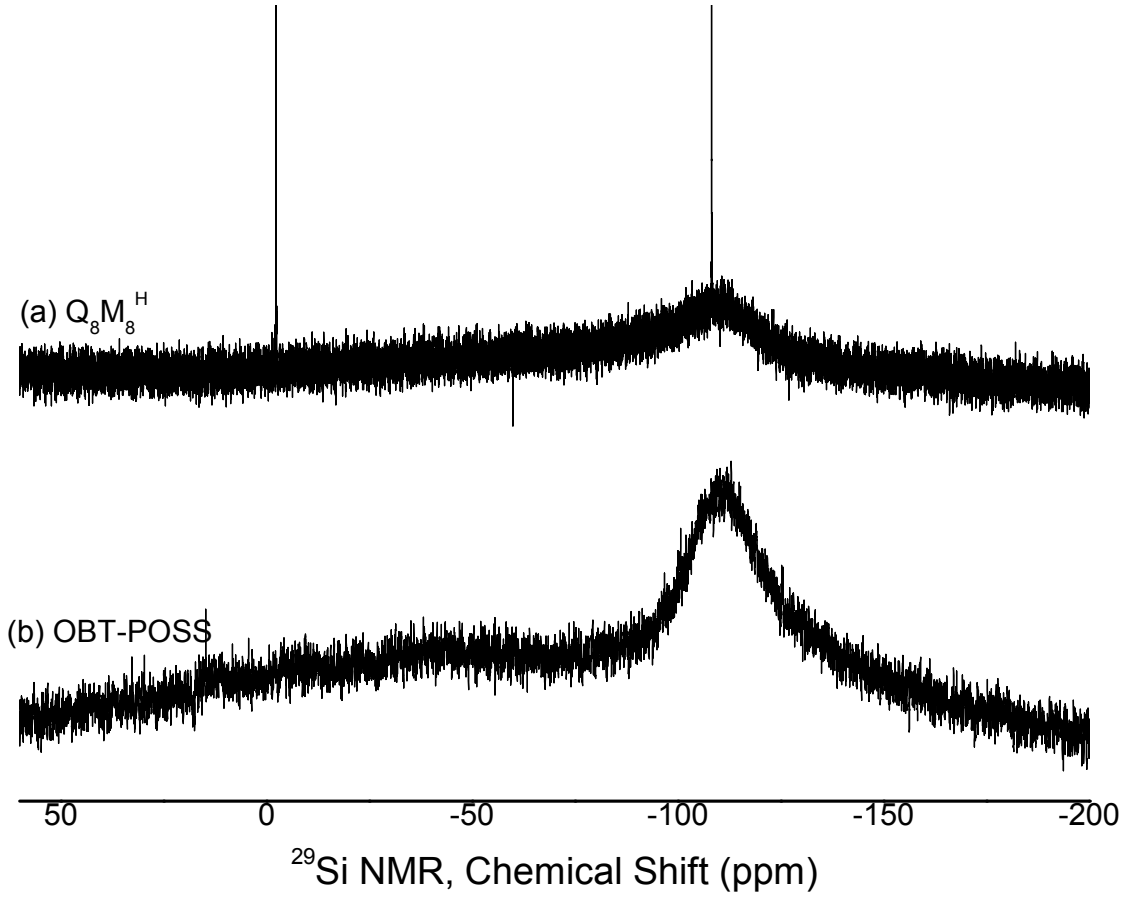

Figure S3: ^{29}Si NMR of (a) $Q_8M_8^H$, and (b) OBT-POSS.

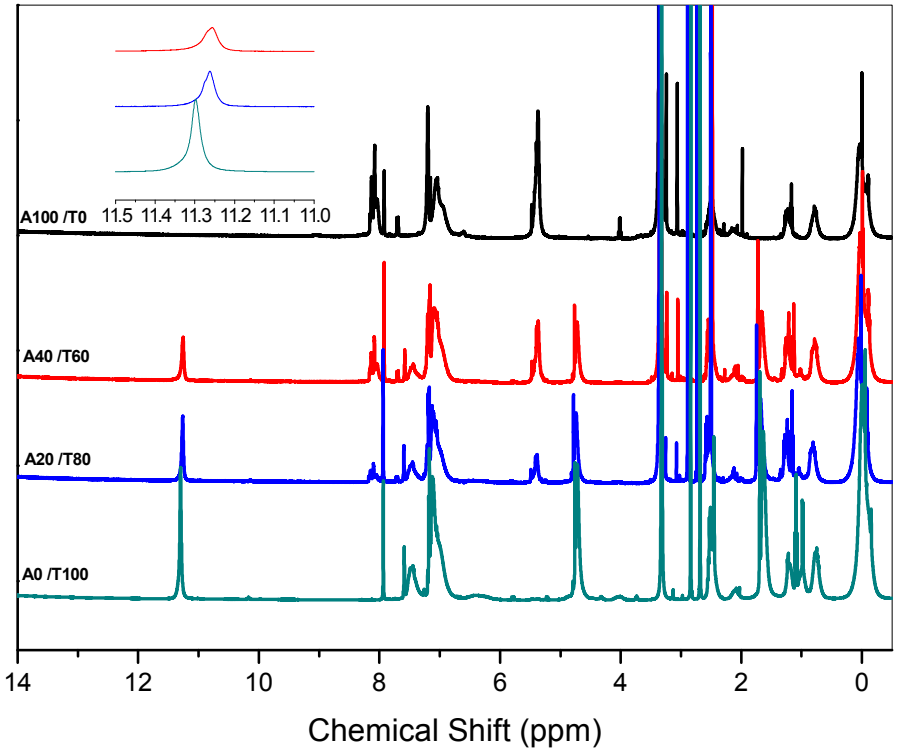

Figure S4: ^{1}H NMR of OBA-POSS/OBT-POSS mixtures with different compositions at room temperature in *d*-DMSO.